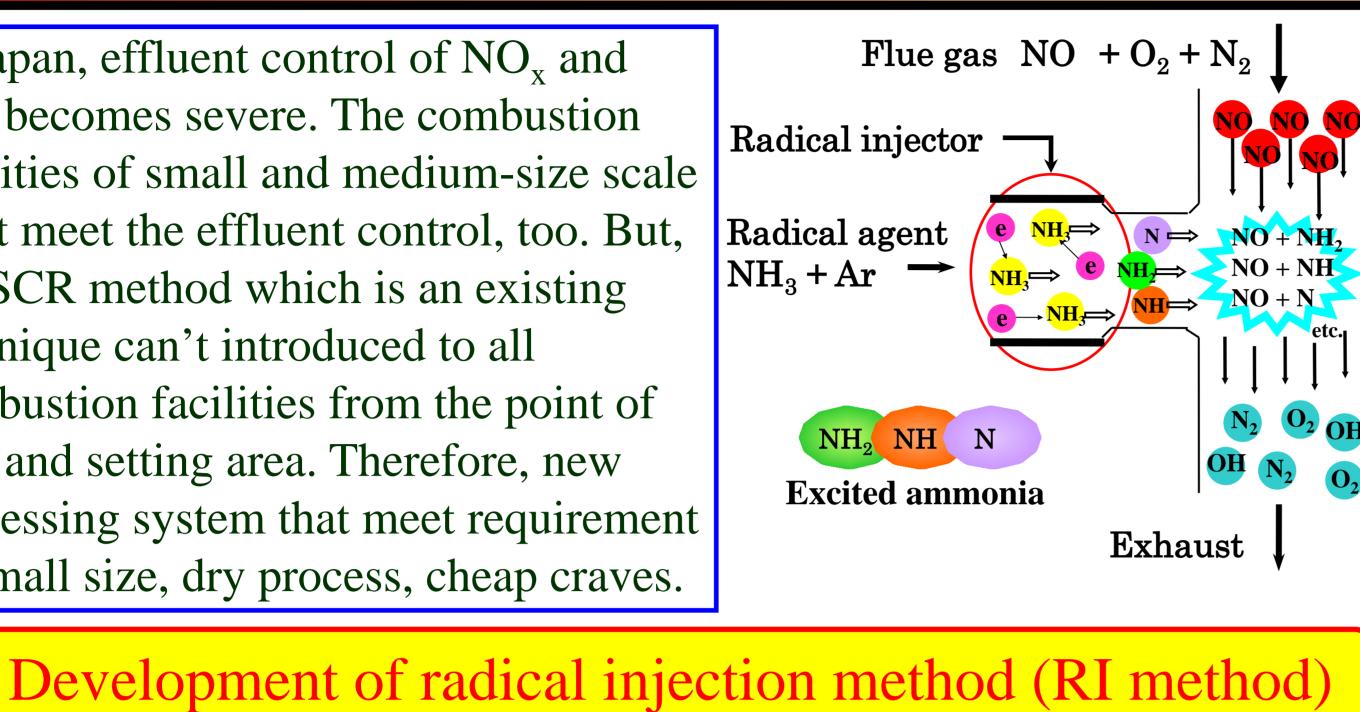
Simultaneous NO_x/SO₂ removal by ammonia gas excited by atmosphere plasma **GIFU UNIVERSITY** S. Kambara, Y. Hayakawa, M. Masui, K. Kumabe, H. Moritomi

Introduction

In Japan, effluent control of NO_x and SO_x becomes severe. The combustion facilities of small and medium-size scale must meet the effluent control, too. But, the SCR method which is an existing technique can't introduced to all combustion facilities from the point of



NO_x and SO_x are

reduced with high efficiency

and low cost

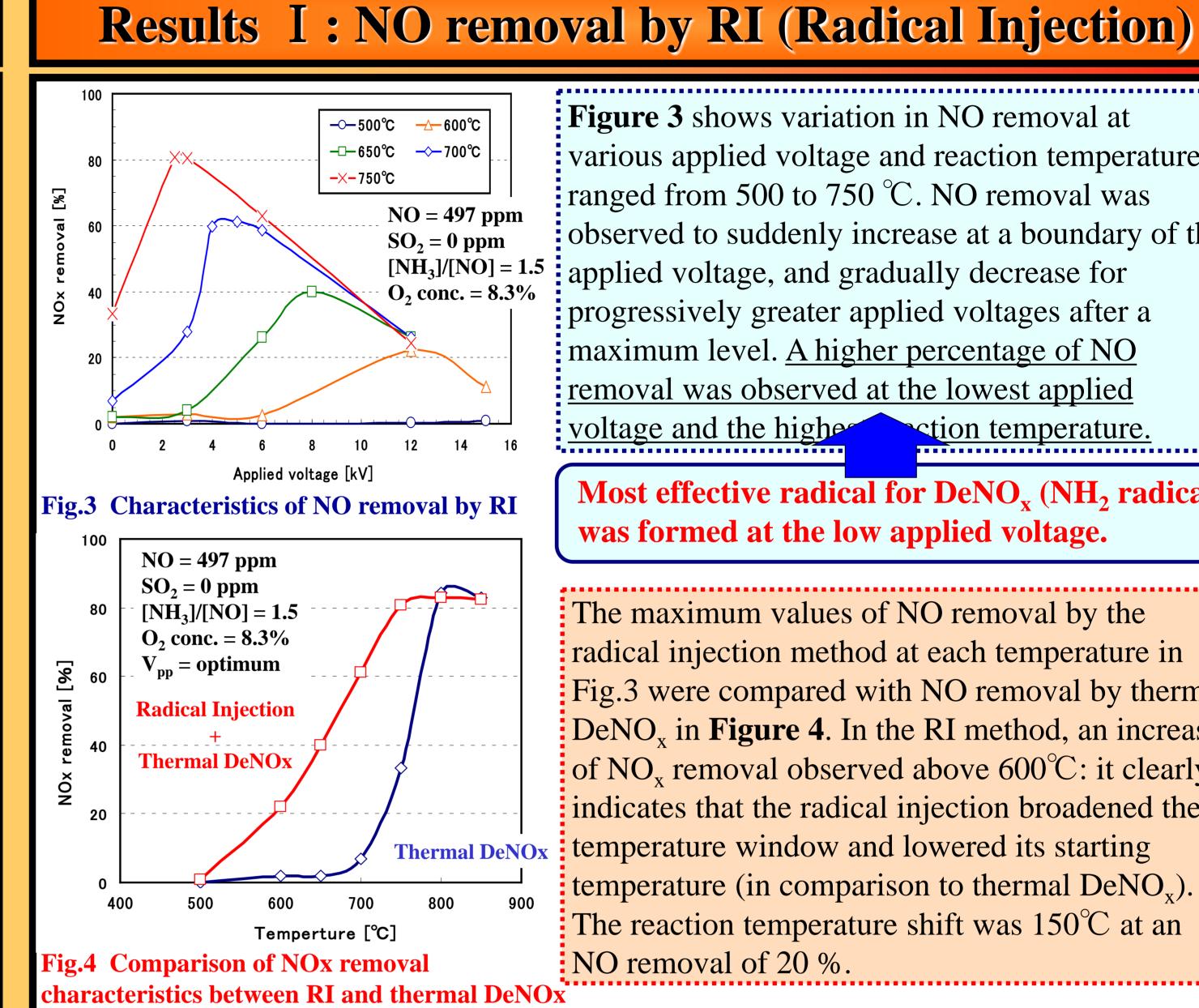
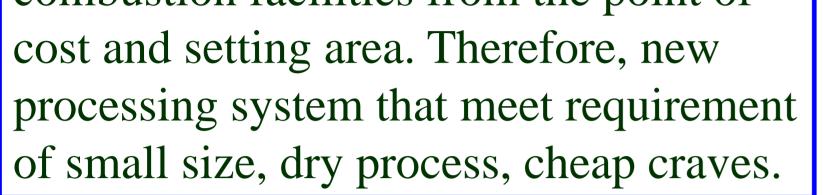


Figure 3 shows variation in NO removal at various applied voltage and reaction temperatures ranged from 500 to 750 °C. NO removal was observed to suddenly increase at a boundary of the applied voltage, and gradually decrease for progressively greater applied voltages after a maximum level. <u>A higher percentage of NO</u> removal was observed at the lowest applied



The advantage of the radical injection method

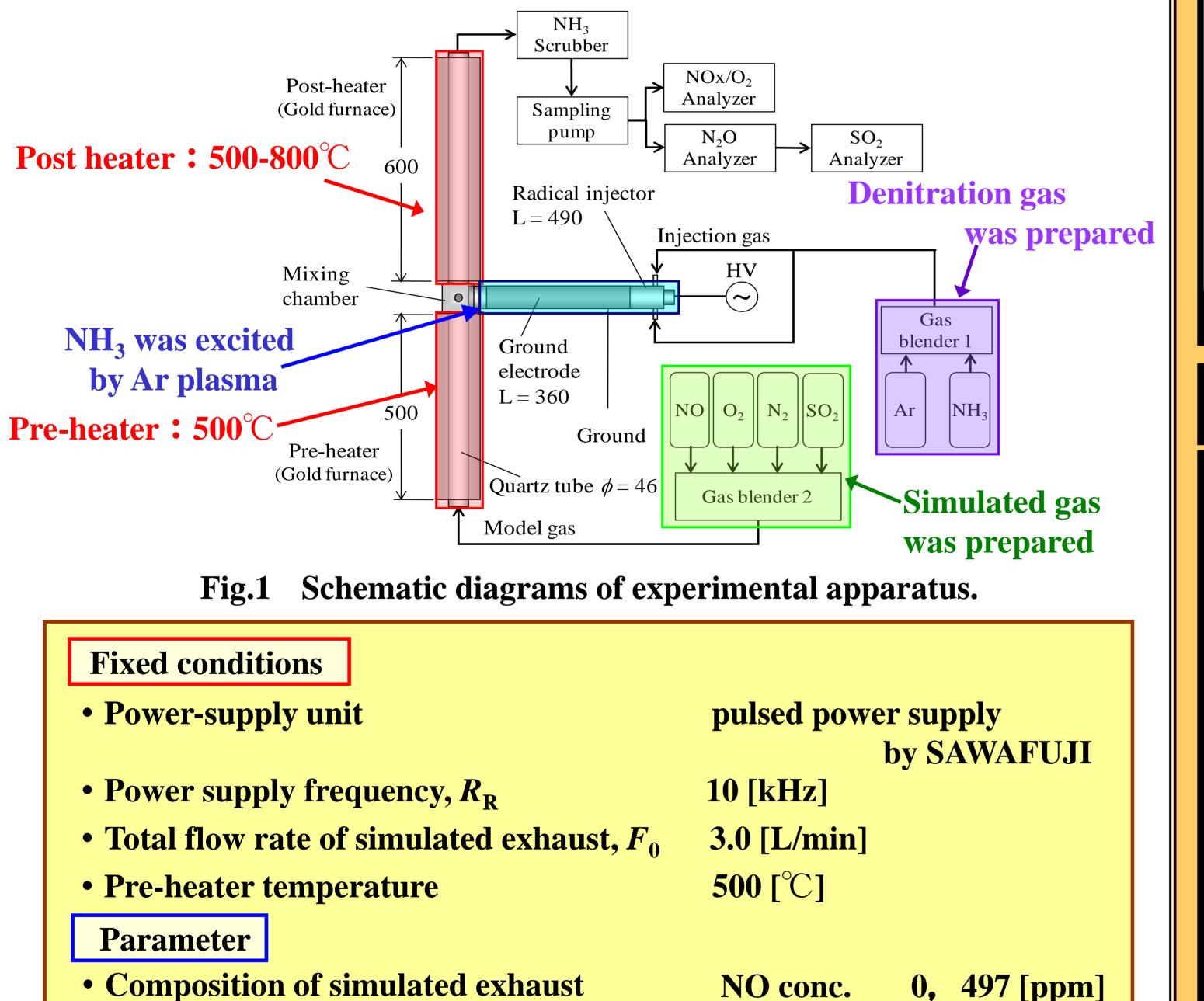
- The device is a simple configuration.
- A coolant and a catalyst are unnecessary.
- A reduction agent (NH₃) only is activated.
 - \rightarrow NH*i* radical is generated by smaller energy

Objectives of this study

SO₂ is usually included in combustion flue gas, it is likely that the DeNOx properties using the radical injection is affected by reaction of SO₂ and NH₃

This study clarifies a radical injection DeNOx characteristic under the condition of the SO₂ exist

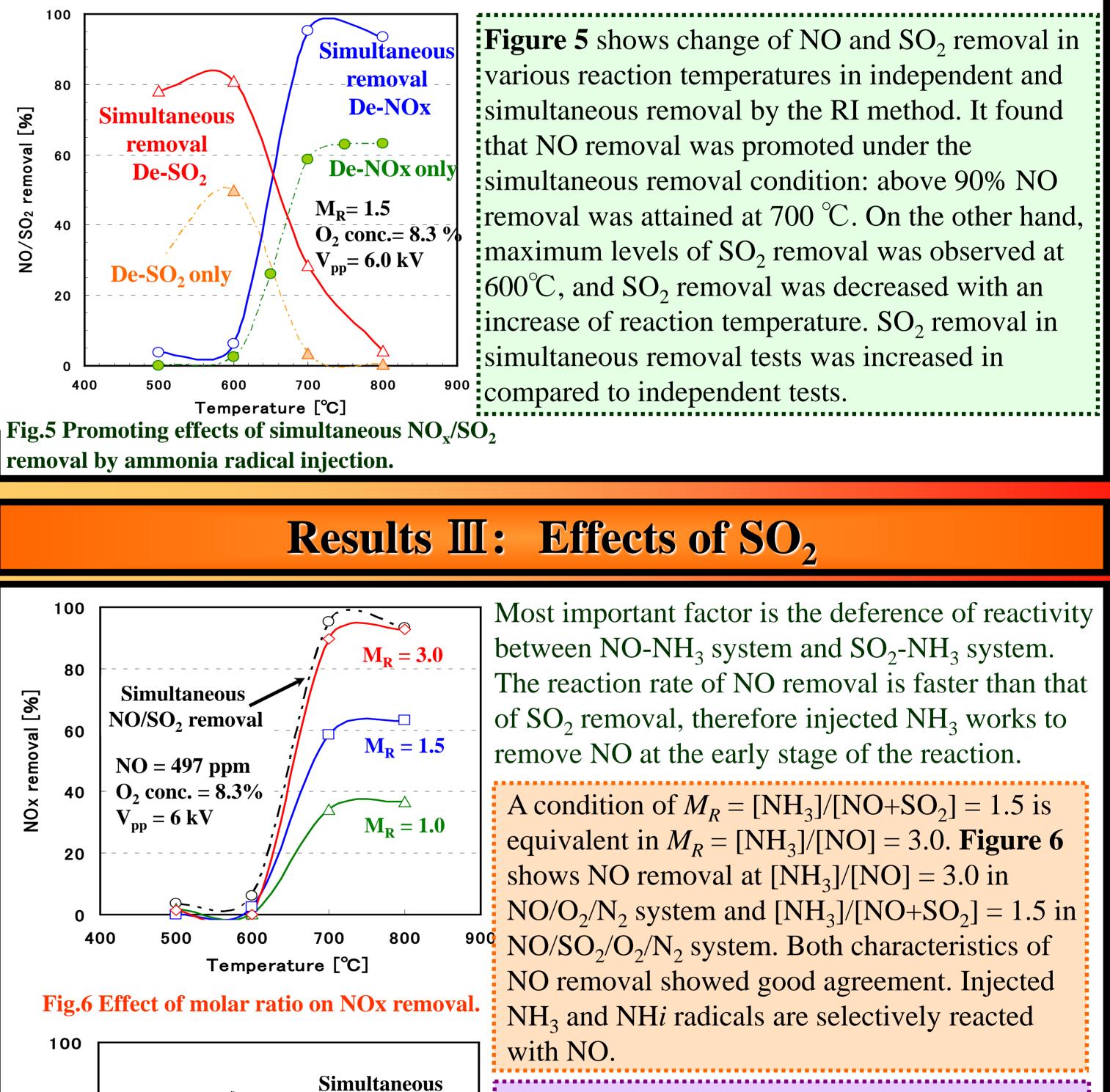
Experimental

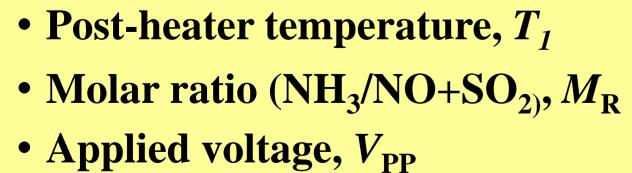


ction temperature. voltage and the higher Most effective radical for DeNO_x (NH₂ radical) was formed at the low applied voltage.

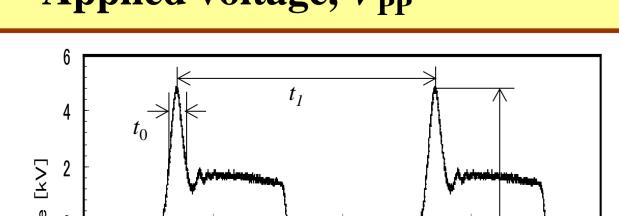
The maximum values of NO removal by the radical injection method at each temperature in Fig.3 were compared with NO removal by thermal $DeNO_x$ in **Figure 4**. In the RI method, an increase of NO_x removal observed above 600° C: it clearly indicates that the radical injection broadened the Thermal DeNOx temperature window and lowered its starting temperature (in comparison to thermal $DeNO_x$). The reaction temperature shift was 150°C at an NO removal of 20 %.

Results II: Simultaneous NO/SO₂ removal by RI





0, 251 [ppm] SO₂ conc. 2.1-8.3 [%] O_2 conc. **500-800** [°C] 1-1.5 [-] 0-15 [kV]



Time [µs]

Fig.2 Waveform of the applied voltage.

/~~

150

+ > -2

- t_1 : Pulse interval
- Wave pattern retention time t_0 :
- $V_{\rm PP}$: Voltage between plus and minus peaks
- $R_{\rm R}$: 1 / T_1 (frequency)

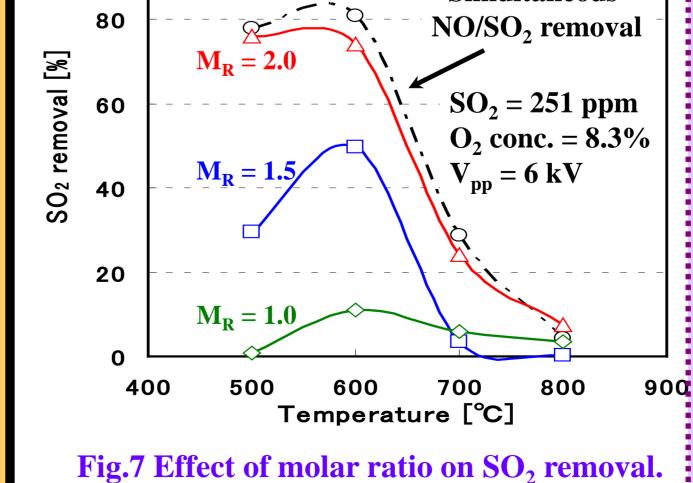


Figure 7 shows SO₂ removal at $[NH_3]/[SO_2] =$ 2.0 in $SO_2/O_2/N_2$ system and $[NH_3]/[NO+SO_2]$ = 1.5 in NO/SO₂/O₂/N₂ system. The reaction of SO₂ removal occurs after the reaction of NO removal, therefore the condition of $M_R = [NH_3]/[NO+SO_2] = 1.5$ is equivalent in $M_R = [NH_3]/[SO_2] = 2.0$, because a part of NH_3 is consumed by NO removal. In fact, SO₂ removal in NO/SO₂/O₂/N₂ system at $M_R = 1.5$ was similar to that in NO/O₂/N₂ at $M_R = 2.0$.

Conclusions

In simultaneous removal tests, NO removal was promoted under the simultaneous removal condition: above 90% NO removal was attained at 700°C. Besides SO₂ removal was increased in $NO/SO_2/O_2/N_2$ system. Effectiveness of NO and SO₂ removal acceleration was explained by the deference of reaction rate between NO-NH₃ system and SO₂-NH₃ system.